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FROM : Aaron B. Karas

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Re: Our Docket No. NEKW 14.868

As per our telephone conversation of earlier this afternoon, enclosed are two draft claims which hopefully will traverse your rejection of claim 3. Present claim 6 can then be amended to be a dependent claim, depending from new claim 22.

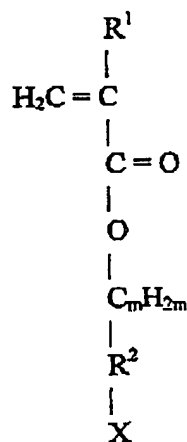
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CLAIMS 21 and 22

21. (New ) A chemically amplified resist comprising photoacid generator contained at 0.2 parts to 25 parts by weight and polymer contained at 75 parts to 99.8 parts by weight and copolymerized between compound and at least one monomer expressed by the general formula:



wherein  $R^1$  represents a hydrogen atom or a methyl group,  $R^2$  represents a bridged hydrocarbon having a carbon number between 7 and 22, m equals 0 or 1 and X is selected from the group consisting of  $C_nH_{2n}$ , COOH and COOR<sup>3</sup> where  $R^3$  represents a hydrogen atom, a methyl



group or an acetyl group,  $R^3$  represents a group decomposed by acid, n equals 0 or 1 and wherein said polymer has an average molecular weight ranging between 1,000 and 50,000.